orm PTO-1449	U.S. Department of Commerce Patent & Trademark Office		Atty. Docket No.	tty. Docket No. Serial No.: NOT YET ASSIGNED			
Rev. 2-32)			Q61184	Confir	Confirmation No.: NOT YET ASSENEI		
	ON DISCLOSURE STAT several sheets if necessary)		Applicant: Toshitaka	AGANO		2.8. 2251	
			Filing Date: April 2, 2001	Group:		0978	
		U.S. PAT	ENT DOCUMENTS			Ţ.	
Examiner Initial	Document Number	Date	Name	Class	Sub- Class	Filing Date (if appropriate)	
1	4,803,359	02/07/89	HOSOI et al	250	327.2		
					-		
					 		
							
			 				
					 		
		FOREIGN PA	ATENT DOCUMENTS		'		
ia	Document	Date	Country	Class	Sub- class	Translation Yes/No	
7/1	-59-211263	11/30/84	JP	H01L	27/14	notprovided	
115	2-164067	06/25/90	JР	H01L	27/146		
(1-216290	08/30/89	JР	G01T	1/24		
	0 898 421 A2	02/24/99	EP	H04N	5/30		
1/	9-222114	08/26/97	-JP	F16B	47/00	- not provided	
V	92/06501	04/16/92	WO	HO1L	27/14	,	
					-		
							
			A 1 0001 00 00				
()			ng Author, Title, Date, P			-	
718	California, Berkeley	, ,	enated Amorphous Silice			· V	
*)	IEEE, Vol. 36, No. 2, NARUSE and TAMOT	April 1989, M	etal/Amorphous Silicon	Multilayer R	Radiation De	tectors, YUJIRO	
- -	Abstract, 02 164067_0		not prov	11elect	-		
	Abstract, 01-216290, 0		11-1 1-00				
V 1		J. J J, J,					
AMINER:	/ //		DATE CONSIDER	ED: 4/	7/04		
XAMINER:	78/-		DATE CONSIDERE	ED: 9//	7/04		